Amendments to the Claims

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

- 1. (Currently amended) A non-volatile memory device comprising:

 an organic ambipolar semiconductor layer in contact with at

 least two sides of a first electrode and a second electrode; and

 an organic ferroelectric layer in contact with one side of

 each of the first electrode and the second electrode and at least

 two sides of a control electrode, said organic ambipolar

 semiconductor layer and said organic ferroelectric layer being at

 least partially in contact with each other.
- 2. (Currently amended) The non-volatile memory device according to claim 1, furthermore comprising awherein the control electrode being is formed in a first conductive layer.
- 3. (Previously presented) The non-volatile memory device according to claim 2, the control electrode being separated from

said organic ambipolar semiconductor layer by said organic ferroelectric layer.

- 4. (Currently amended) The non-volatile memory device according to claim 2, furthermore comprising awherein the first main electrode and a the second main—electrode being are formed in a second conductive layer, said first and said second main—electrodes being separated from each other by material of the organic ambipolar semiconductor layer, and said first and said second main electrodes being separated from said control electrode by said organic ferroelectric layer.
- 5. (Previously presented) The non-volatile memory device according to claim 2, wherein the first conductive layer is a conductive polymer layer.
- 6. (Previously presented) The non-volatile memory device according to claim 5, wherein the conductive polymer layer is a PEDOT/PSS layer or a PANI layer.

- 7. (Previously presented) The non-volatile memory device according to claim 4, wherein the second conductive layer is a conductive polymer layer.
- 8. (Previously presented) The non-volatile memory device according to claim 7, wherein the conductive polymer layer is a PEDOT/PSS layer or a PANI layer.
- 9. (Previously presented) The non-volatile memory device according to claim 1, wherein the organic ferroelectric layer is a ferroelectric polymer or oligomer layer.
- 10. (Previously presented) The non-volatile memory device according to claim 9, wherein the ferroelectric polymer or oligomer layer is a layer comprising material selected from: $(CH2-CF2)_n$, $(CHF-CF2)_n$ $(CF2-CF2)_n$ or combinations thereof to form (random) copolymers including $(CH2-CF2)_n$ - $(CHF-CF2)_m$ or $(CH2-CF2)_n$ - $(CF2-CF2)_m$.
- 11. (Previously presented) The non-volatile memory device according to claim 1, wherein the organic ambipolar semiconductor

layer comprises a mixture of an n-type and a p-type semiconductor material.

- 12. (Previously presented) The non-volatile memory device according to claim 11, wherein the organic ambipolar semiconductor layer comprises a mixture of [6,6]-phenyl C61 butyric acid methyl ester and poly[2-methoxy,5-(3,7) dimethyl-octyloxy]-p-phenylene vinylene.
- 13. (Previously presented) The non-volatile memory device according to claim 1, wherein the organic ambipolar semiconductor layer comprises a single organic material.
- 14. (Previously presented) The non-volatile memory device according to claim 13, wherein the single organic material is poly(3,9-di-tert-butylindeno[1,2-b] fluorene).
- 15. (Previously presented) The non-volatile memory device according to claim 1, the memory device comprising a memory window, whereby said memory window depends on a ratio of electron current

and hole current.

- 16. (Previously presented) The non-volatile memory device according to claim 15, whereby said ratio of electron current and hole current is close to 0 or close to 1.
- 17. (Currently amended) A method for processing a non-volatile memory device, the method comprising acts of:

forming an organic ferroelectric layer in contact with at least two sides of a first electrode and a second electrode; and

forming an organic ambipolar semiconductor layer in contact with one side of each of the first electrode and the second electrode and at least two sides of a control electrode, said organic ambipolar semiconductor layer and said organic ferroelectric layer being at least partially in contact with each other.

18. (Currently amended) A non-volatile memory device comprising:
 first and second electrodes;
 a control electrode;

an organic ambipolar semiconductor layer in contact with three sides of said first and second electrodes; and

an organic ferroelectric layer in contact with one side of each said first and second electrodes, at least_two sides of said control electrode and at least partially in contact with said organic ambipolar semiconductor layer.

19. (Previously presented) The device of claim 18, further comprising a planarization layer in contact with one side of said control electrode.